## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q84137

Shinichi ISHIBASHI, et al.

Appln. No.: National Stage Entry of PCT/JP03/04615

Confirmation No.: Not yet assigned Group Art Unit: Not yet assigned

Filed: October 12, 2004 Examiner: Not yet assigned

For: REFLECTIVE MASK BLANK, REFLECTIVE MASK AND METHODS OF

PRODUCING THE MASK BLANK AND THE MASK

## **SECOND PRELIMINARY AMENDMENT**

## MAIL STOP AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Prior to examination, please amend the above-identified application as follows on the accompanying pages.